Amendments to the Specification

Please replace the paragraph beginning at page 3, line 25, with the following rewritten paragraph:

--Another advantage of at least one embodiment of the present invention is that the removable shadow mask may be reused. Using a removable mask may also allows allow for a simpler process because it does not require applying material (e.g., photoresist) on the substrate to form a mask. A removable mask also results in a substantially planar substrate (after deposition and removal of the mask), which can be easier to use in subsequent processing steps.--